

شبكة المعلومات الجامعية







شبكة المعلومات الجامعية التوثيق الالكتروني والميكروفيلم



شبكة المعلومات الجامعية

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التوثيق الالكتروني والميكروفيلم

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SIMULATION AND MODELING OF TUNNELING CARBON NANOTUBES FIELD EFFECT TRANSISTORS (T-CNFETS)

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By

Mohamed Nabil Mohamed Mostafa El-Zeftawi

B.Sc. in Electronics and Communications Engineering - Cairo University

A Thesis Submitted to the
Faculty of Engineering at Cairo University
in Partial Fulfillment of the
Requirements for the Degree of
Master of Science
in
Engineering Physics

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Faculty of Engineering, Cairo University
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Faculty of Engineering, Cairo University Giza, Egypt July 2007 to mile



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